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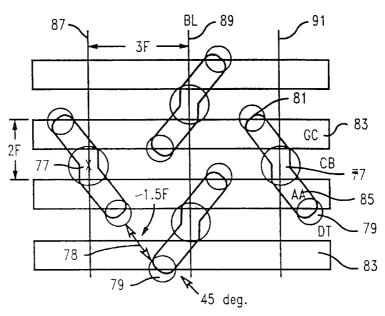
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(54) Title: TRENCH CAPACITOR DRAM CELL LAYOUT



(57) Abstract: A layout pattern for increasing the spacing between the deep trenches (79, 81) of one cell pair and the deep trenches of an adjacent cell pair in an array of semiconductor DRAM cell pairs each of which cell pairs share a common bitline contact (77) to bitlines (87, 89, 91) arranged in one direction and each of which cell pairs are coupled to gate conductors (83) arranged orthogonal to the bitlines. The layout pattern is formed by positioning the deep trenches of all of said pairs along alternate bitlines so they are offset from said bitlines along gate conductors in opposing directions. The deep trenches of all of the remaining bitlines are offset from said bitlines in opposing directions opposite to the opposing directions of said trenches along said alternate bitlines so as to form a herringbone pattern of cells.



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According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

 $\label{lower_model} \begin{tabular}{ll} \beg$

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

EPO-Internal

Category °	Citation of document, with indication. where appropriate, of the relevant passages	Relevant to claim No.
X	US 5 559 350 A (KABUSHIKI KAISHA TOSHIBA) 24 September 1996 (1996-09-24) column 6, line 57 -column 7, line 31; figure 13 column 12, line 14 - line 17; figure 40	1-16
Y	EP 0 428 247 A (FUJITSU LTD) 22 May 1991 (1991-05-22) abstract; figures 2,11-13,21	1-16
Y	US 5 305 252 A (NEC CORP) 19 April 1994 (1994-04-19) column 13, line 5 - line 9; figure 13	1-16
Α	US 5 461 248 A (GOLDSTAR ELECTRON CO LTD) 24 October 1995 (1995-10-24) abstract; figures 1,2 -/	1-16

X Further documents are listed in the continuation of box C.	Patent family members are listed in annex.
Special categories of cited documents: A' document defining the general state of the art which is not considered to be of particular relevance E' earlier document but published on or after the international filing date L' document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) O' document referring to an oral disclosure, use, exhibition or other means P' document published prior to the international filing date but later than the priority date claimed	 'T' later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention 'X' document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone 'Y' document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art. '&' document member of the same patent family
Date of the actual completion of the international search 13 December 2001	Date of mailing of the international search report $20/12/2001$
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PC I/US 01/20175

	ation) DOCUMENTS CONSIDERED TO BE RELEVANT			
itegory °	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.		
	US 5 177 576 A (HITACHI LTD) 5 January 1993 (1993-01-05) abstract; figures 6A-6G	1-16		
	abstract; figures 6A-6G EP 0 884 785 A (SIEMENS AG) 16 December 1998 (1998-12-16) abstract; figures	1-16		

INTERNATIONAL SEARCH REPORT

information on patent family members

Int tional Application No
PCI/US 01/20175

Patent document cited in search report		Publication date		Patent family member(s)	Publication date
US 5559350	Α	24-09-1996	NONE		
EP 0428247	-	22-05-1991	JP	2974252 B2	10-11-1999
			JP	3214670 A	19-09-1991
			US	5812 444 A	22-09-1998
			DΕ	69030426 D1	15-05-1997
			DE	69030426 T2	17-07-1997
			EP	0428247 A2	22-05-1991
			EP	0756327 A1	29-01-1997
			EP	0762502 A1	12-03-1997
			KR	9509388 B1	21-08-1995
			US	6026010 A	15-02-2000
US 5305252	A	19-04-1994	JP	2792211 B2	03-09-1998
			JP	4065872 A	02-03-1992
			DE	69121483 D1	26-09-1996
			DE	69121483 T2	27-03-1997
			EP	0464686 A1	08-01-1992
			KR	9603659 B1	21-03-1996
US 5461248	A	24-10-1995	KR	9406681 B1	25-07-1994
			DE	4233486 A1	15-04-1993
			JP	5218335 A	27-08-1993
			US	5346845 A	13-09-1994
US 5177576	Α	05-01-1993	JP	4014868 A	20-01-1992
EP 0884785	 А	 16-12-1998	 CN	1202012 A	 16-12-1998
			EP	0884785 A2	16-12-1998
			JP	11017151 A	22-01-1999
			TW	425718 B	11-03-2001